

09/936289

JCEP Rec'd PCT PTO

12 SEP 2001

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

ATTY.'S DOCKET: SATO=22

In re Application of:
Taizo SATO et al.

Art Unit:

Examiner:

I.A. No.: PCT/JP00/01402

Washington, D.C.

Filed: March 8, 2000

September 12, 2001

For: MATERIAL FOR SHADOW MASK...

PRELIMINARY AMENDMENTHonorable Commissioner for Patents and Trademarks
Washington, D.C. 20231

Sir:

Contemporaneous with the filing of this case and prior to calculation of the filing fee, kindly amend as follows:

IN THE SPECIFICATION

After the title please insert the following paragraph:

REFERENCE TO RELATED APPLICATIONS

--The present application is the national stage under 35 U.S.C. §371 of international application PCT/JP00/01402, filed March 8, 2000 which designated the United States, and which application was not published in the English language.--

IN THE CLAIMS

Please amend claim 5 as follows:

5. (Amended) Shadow mask made of the material as claimed in claim 1.

5/Prelim
3/12/01
Jhn

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a1

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a2